



FORM: PTO-14 (REV: 7-80)	U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE		Atty Docket No: <b>94-0280.03</b>	Serial No: <b>09/471,460</b>
<b>INFORMATION DISCLOSURE STATEMENT BY APPLICANT</b> (37 CFR 1.98(b))		Applicant: <b>Thomas A. Figura et al.</b>		
		Filing Date: <b>12/22/99</b>	Group: <b>2825</b>	

**U.S. PATENT DOCUMENTS**

Examiner Initial	Document Number	Date	Name	Class	Subclass
CL	AA 6,117,764	09/12/00	Figura et al.	438	623
CL	AB 5,950,092	09/07/99	Figura et al.	438	399
AC					
AD					
AE					
AF					
AG					
AH					
AI					
AJ					
AK					
AL					
AM					
AN					
AO					
AP					
AQ					

**FOREIGN PATENT DOCUMENTS**

Examiner Initial	Document Number	Date	Country	Class	Subclass	Translation Yes	Translation No
	AR					<input type="checkbox"/>	<input checked="" type="checkbox"/>
	AS					<input type="checkbox"/>	<input checked="" type="checkbox"/>

Initial

**OTHER ART** (including author, title, date, pertinent pages, etc.)

CL	AT		Application Serial No. 09/470,650, entitled USE OF A PLASMA SOURCE TO FORM A LAYER DURING THE FORMATION OF A SEMICONDUCTOR DEVICE, filed December 22, 1999; Thomas A. Figura, Kevin Donohoe, and Thomas Dunbar, inventors; attorney docket No. 94-0280.04; Preliminary Amendment filed December 22, 1999; Response to the Office Action dated May 3, 2001, filed May 21, 2001.
CL	AU		Application Serial No. 09/470,651, entitled USE OF A PLASMA SOURCE TO FORM A LAYER DURING THE FORMATION OF A SEMICONDUCTOR DEVICE, filed December 22, 1999; Thomas A. Figura, Kevin Donohoe, and Thomas Dunbar, inventors; attorney docket No. 94-0280.05; Preliminary Amendment filed December 22, 1999; Amendment After the Continued Prosecution Application and Response to the Office Action dated April 13, 2000 filed July 13, 2000; Response to the Office Action dated September 26, 2000 filed October 5, 2000; Amendment and Response to the Office Action dated November 21, 2000, filed May 21, 2001.

Examiner:

culowles

Date Considered:

6.12.01

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication with applicant.